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LETTERS

Synthesis and oxidation reactions of cycloheptatrienyl sulfones

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Abstract

Inexpensive cycloheptatriene is regiospecifically converted to all three phenylsulfonyl substituted cycloheptatrienes. Epoxidation of these materials with achiral reagents is shown to be relatively regiospecific. Reasonable levels of enantiomeric excess ($\sim 63.78\%$) are achieved by Sharpless asymmetric dihydroxylation of a pair of 3-substituted trienes. Crystallization of these sulfones provides the diols in enantiomeric excesses greater than 90%. © 2000 Published by Elsevier Science Ltd.

Multiply convergent synthetic strategies place high value upon efficient construction of assemblies such as **1**, which are typically employed as sub-goals as a prelude to assembly of the final target. We are currently exploring the synthesis of optically pure termini-differentiated hexyl (**1a**, $n=6$) and heptyl (**1b**, $n=7$) compounds bearing up to five contiguous chiral centers (Fig. 1).¹

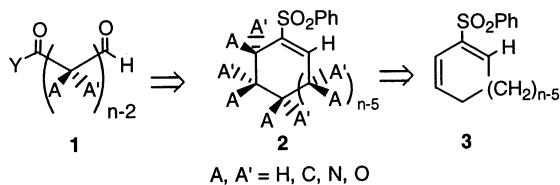


Figure 1.

Preparation of the full family of prochiral trienyl sulfones from inexpensive cycloheptatriene is of general significance since these materials may now be examined as starting materials for a variety of potentially enantiospecific cycloaddition and conjugate-addition/alkylation reactions. For example, we speculated that trienyl sulfones such as **4** might serve as substrates for a sequence of nucleophilic and electrophilic functionalizations which ultimately afford generic

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sulfone **5** after elimination of a molecule of HE_3 . Completion of the hypothetical synthesis would then involve oxidative scission of the vinyl sulfone functionality to deliver substrate **6** appropriately functionalized for further connective operations. Clearly, such an approach raises a myriad of enantio-, stereo-, regio-, and chemoselectivity questions, but before these can be addressed, effective access to this unknown class of compounds needed to be achieved (Fig. 2).

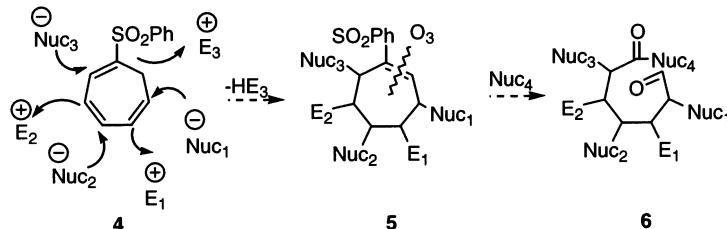


Figure 2.

Cycloheptatriene **7** is an ideal substrate for synthesis of multiply-functionalized 7-membered ring vinylsulfones because of its insignificant cost and high oxidation state.² Reaction of **7** with phenylsulfenylchloride, prepared in situ from thiophenol and *N*-chlorosuccinimide,³ afforded a mixture of adducts which were not separated, but directly oxidized to the chlorosulfones and treated with triethylamine to converge to 1-substituted trienylsulfone **4** as a single regioisomer in 68% overall yield (Fig. 3).

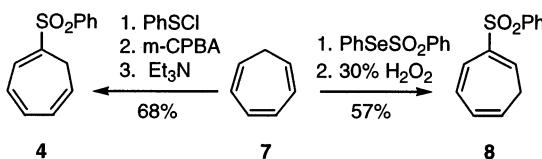


Figure 3.

Synthesis of the 2-substituted triene **8** in 57% overall yield was accomplished by addition of the Back phenylselenylsulfonate reagent⁴ to cycloheptatriene **7** followed by oxidation and elimination with hydrogen peroxide. Synthesis of the 3-substituted triene **12** was more difficult. Treatment of cycloheptatriene **7** to generate tropylidium fluoroborate⁵ followed by addition of thiophenol provided 7-thiophenyl cycloheptatriene **9**⁶ in 71% yield. Thermal rearrangement of 0.05 M triene **9** with 0.05 equiv. hydroquinone in benzene at 185°C for 1 h (sealed tube) provided 3-thiophenyl-cycloheptatriene **10** in a modest 46% yield along with 43% recovered **9**. Extending the reaction time to 19 h delivers 1-thiophenyl-cycloheptatriene **11** in 41% along with 19% recovered **9**, but only traces of **10** remain. Relative R_f values (SiO_2 –100% hexane) for **9**, **10**, and **11** are 0.25, 0.49, and 0.51, respectively, which allows ready separation of **9** and **10**. Oxidation of **10** gives the requisite sulfone **12** in 89% yield (Fig. 4).

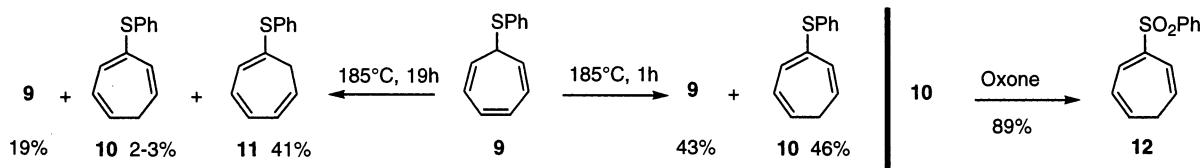
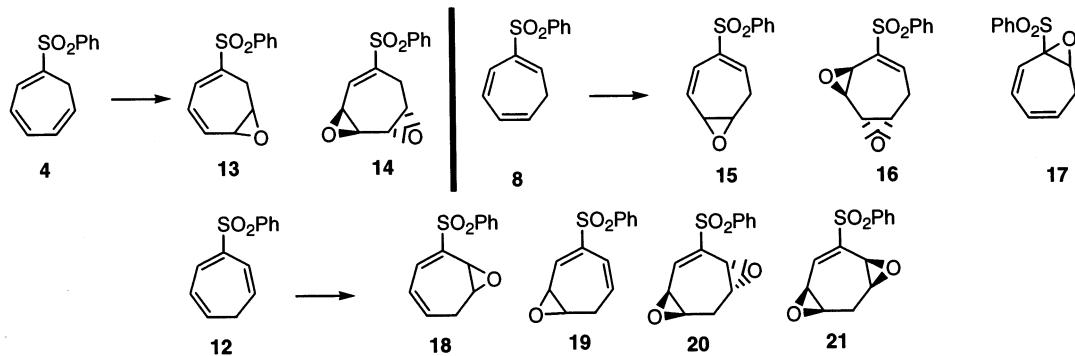


Figure 4.

Epoxidation of the three cycloheptenyl sulfones was evaluated using both achiral and chiral reagents. The trienyl substrates were substantially less reactive than the parent 2-phenylsulfonyl-cyclohepta-1,3-diene **3b**. While **3b** is a premier substrate for Jacobsen epoxidation,^{1c} it is clear from Table 1 that addition of the third double bond deactivates the substrate and serves to decrease the facial specificity, presumably due to resonance-related flattening of the cyclohepta-1,3-diene ring (Table 1).

Table 1
Achiral and Jacobsen epoxidations^a



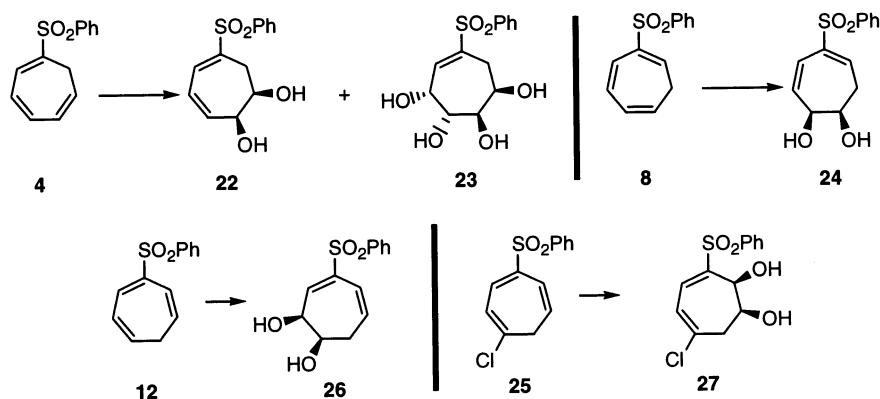
SM	Conditions	Product(s)	Yield (%)	SM	Conditions	Product(s)	Yield (%)
4	A	13	40 (41% ee)	4	E	13:14 (2.3:1)	75
4	B	13	40 (37% ee)	4	D	13	23
4	C	13	38	8	A	15	28
8	B	15	33	8	F	15	85
8	G	16	87	8	H	17	65
8	I	17	95	12	A	—	12 recovered
12	B	—	12 recovered	12	J	18:20 (1.3:1)	89
12	E	20:21 (12:1)	85	12	C	18:19 (2:1)	10

^a Conditions: A: (*R,R*)-Jac. cat. (0.08 equiv.), P₃NO (0.32 equiv.), 12% bleach (3 equiv.), MC, 0°C, 5 h; B: (*S,S*)-Jac. cat. (0.08 equiv.), P₃NO (0.32 equiv.), 12% bleach (3 equiv.), MC, 0°C, 5 h; C: (*R,R*)-Jac. cat. (0.2 equiv.), NH₄OAc (0.25 equiv.), 30% H₂O₂ (3 equiv.), MC-MeOH (1:1), 0°C, 6 h; D: (*S,S*)-Jac. cat. (0.2 equiv.), NH₄OAc (0.25 equiv.), 30% H₂O₂ (3 equiv.), MC-MeOH (1:1), 0°C, 6 h; E: Na₂EDTA (0.003 equiv.), trifluoroacetone (10 equiv.), Oxone® (7.8 equiv.), NaHCO₃ (5 equiv.), MeCN, 0°C, 1 h; F: *m*-CPBA (2.5 equiv.), MC, rt, 28 h; G: Na₂EDTA (0.003 equiv.), trifluoroacetone (10 equiv.), Oxone® (7.8 equiv.), NaHCO₃ (5 equiv.), MeCN, 0°C, 0.5 h; H: 30% H₂O₂ (5 equiv.), NaOH (1 equiv.), MeOH; I: *n*-BuLi (1.2 equiv.), *t*-BuOOH (1.5 equiv.), THF, -40°C, 3 h; J: *m*-CPBA (2.5 equiv.), MC, rt, 12 h; 0°C, 7 h.

Sharpless asymmetric dihydroxylation of trienyl sulfones **4** and **8** was also disappointing. In contrast, although slow, reaction of **12** and **25** provided reasonable levels of asymmetric induction. In fact, one recrystallization of diol **27** served to remove crystalline racemic material providing **27** with >90% ee as the ‘crystallization residue’ (Table 2).

Synthesis of chlorinated trienylsulfone **25** was accomplished by treatment of cycloheptane-1,3-dione **28**⁷ with oxalyl chloride to give vinyllogous acid halide **29**. Bis-sulfenylation of **29** with phenylsulfenyl chloride in THF afforded thioacetal **30** in 70% yield. DIBAL-H reduction of **30** smoothly provided allylic alcohol **31** in near-quantitative yield. Compound **31** is thus conveniently prepared on a 25 g scale.

Table 2
Sharpless dihydroxylation^a



SM	Reaction time (h)	Product(s)	Yield (%)	ee (%)
4	46	22:23 (4:1)	75	36
8	46	24	73	38
12	10	26	51	63
25	120	27	45 ^b	78

^a Conditions: (DHQ)₂PHAL (0.1 equiv.) or (DHQD)₂PHAL (0.1 equiv.), K₃Fe(CN)₆ (3 equiv.), K₂CO₃ (3 equiv.), OsO₄ (0.1 equiv.), MeSO₂NH₂ (3 equiv.), *t*-BuOH/H₂O, 0°C.

^b Based upon recovered starting material; 18% absolute yield, (DHQ)₂PHAL as ligand.

The key reaction in this sequence is the reaction of **31** with three equivalents of *m*-CPBA which provides vinylsulfone **32**, presumably regiospecific via loss of sulfinic acid from the α -sulfinylsulfone intermediate. Treatment of alcohol **32** with mesyl chloride in the presence of excess triethylamine effects 1,4-elimination to chloro-substituted triene **25**⁸ as a single regioisomer. This specificity results from the inductive acidification of the sulfone-bearing γ -hydrogen (Fig. 5).

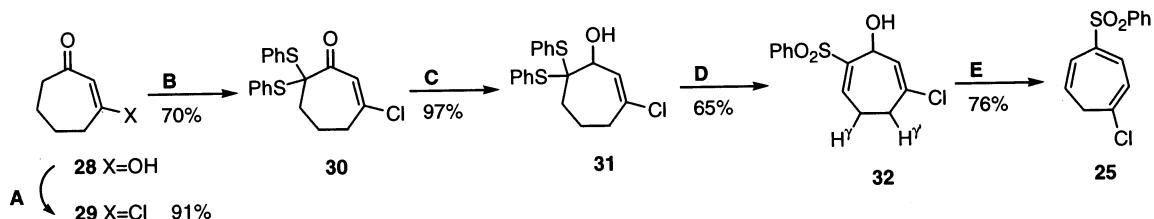


Figure 5. Conditions: A: (COCl)₂ (1.2 equiv.), CHCl₃, rt, 5 h; B: PhSCl (2.2 equiv.), THF–HMPA (10:1), 0°C, 2 h; C: DIBAL-H (1.5 equiv.), MC, -78°C, 2 h; D: *m*-CPBA, MC, rt, 1 h; E: MsCl (1.5 equiv.), Et₃N (3 equiv.), MC, 0°C, 0.5 h

Acknowledgements

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- 1-Benzenesulfonyl-1,3,5-cycloheptatriene (4)**: ¹H NMR (500 MHz, CDCl₃): 7.91–7.94 (m, 2H), 7.51–7.64 (m, 3H), 7.26 (d, *J*=0.48 Hz, 1H), 6.76 (q, *J*=5.62 Hz, 1H), 6.62–6.66 (m, 1H), 6.21 (dd, *J*=5.62 and 9.52 Hz, 1H), 5.33–5.38 (m, *J*=0.49, 6.84, and 9.52 Hz, 1H), and 2.59 (d, *J*=6.84 Hz, 2H); **2-benzenesulfonyl-1,3,5-cycloheptatriene (8)**: ¹H NMR (500 MHz, CDCl₃): 7.75–7.79 (m, 2H), 7.44–7.59 (m, 3H), 6.84 (dt, *J*=0.46 and 11.44 Hz, 1H), 6.71–6.79 (m, *J*=5.49, 5.65 and 11.44 Hz, 1H), 6.48 (td, *J*=0.46 and 7.44, 1H), 6.13 (dd, *J*=5.49 and 9.46 Hz, 1H), 5.46 (dt, *J*=6.57 and 9.46 Hz, 1H), and 2.41 (dd, *J*=6.87 and 7.17 Hz, 2H); **3-benzenesulfonyl-1,3,5-cycloheptatriene (12)**: ¹H NMR (300 MHz, CDCl₃): 7.91–7.95 (m, 2H), 7.73 (d, *J*=6.87 Hz, 1H), 7.55–7.58 (m, 3H), 6.53 (d, *J*=9.61 Hz, 1H), 6.37 (dd, *J*=5.96 and 9.31 Hz, 1H), 5.62 (dt, *J*=6.87 and 9.31 Hz, 1H), 5.43 (dt, *J*=6.87 and 9.61 Hz, 1H), and 2.25 (t, *J*=6.87, 2H); **5,6-epoxy-2-benzenesulfonyl-1,3-cycloheptadiene (15)**: ¹H NMR (500 MHz, CDCl₃): 7.85–7.89 (m, 2H), 7.09 (t, 1H), 7.49–7.63 (m, 3H), 3.53–3.57 (m, 1H), 6.17–6.27 (m, *J*=5.62 and 11.72 Hz, 2H), 3.09 (dt, *J*=3.18 and 3.42 Hz, 1H), 2.93 (ddd, *J*=2.93, 5.62 and 14.89 Hz, 1H), and 2.65 (ddd, *J*=5.62, 7.57 and 14.77 Hz, 1H); **5,6-dihydroxyl-1-benzenesulfonyl-1,3-cycloheptadiene (22)**: ¹H NMR (500 MHz, CDCl₃): 7.84–7.88 (m, 2H), 7.50–7.64 (m, 3H), 7.16 (dt, *J*=3.51 Hz, 1H), 6.08 (q, 2H), 4.31–4.33 (m, 1H), 3.95–4.00 (m, 1H), 2.65 (dd, *J*=0.92 and 6.41 Hz, 2H), and 2.24 (s, br, -OH); **5,6-dihydroxyl-2-benzenesulfonyl-1,3-cycloheptadiene (24)**: ¹H NMR (500 MHz, CDCl₃): 7.83–7.89 (m, 2H), 7.50–7.65 (m, 3H), 7.26 (t, 1H), 6.18 (d, 1H), 5.97 (dd, 1H), 4.77 (s, br, -OH), 4.25 (s, br, 1H), 4.08–4.14 (m, 1H), 2.71 (t, 2H); **1-chloro-4-benzenesulfonyl-cyclohepta-1,3,5-triene (25)**: ¹H NMR (300 MHz, CDCl₃): 7.88–7.92 (m, 2H), 7.52–7.63 (m, 4H), 6.61 (d, *J*=9.3 Hz, 1H), 6.54 (d, *J*=6.6 Hz, 1H), 5.65 (dt, *J*=9.3, 6.9 Hz, 1H), and 2.76 (d, *J*=6.9 Hz, 2H). **1-chloro-4-benzene-sulfonyl-5,6-dihydroxy-cyclohepta-1,3-diene (27)**: ¹H NMR (300 MHz, C₆D₆): 7.90–7.96 (m, 2H), 7.10–7.15 (m, 3H), 7.01 (d, *J*=8.7 Hz, 1H), 5.81 (dd, *J*=2.7, 8.7 Hz, 1H), 4.85 (br s, 1H), 3.93 (br s, 1H), 3.59 (br d, *J*=11.1 Hz, 1H), 3.32 (ddd, *J*=2.7, 11.1, 18.3 Hz, 1H), 3.05 (br s, 1H), 2.63 (br d, *J*=18.3 Hz, 1H).